

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Currently Amended) An installation {2} comprising a machine {4} for the production of tablets, where the machine has at least one enclosure {6, 8, 10}, characterised in that wherein the installation includes means {10, 12, 16, 14} for injecting a gas into the enclosure and to distribute it throughout the enclosure, said means being arranged so as to control the temperature of the gas at a predetermined location {80} upstream of the enclosure {6} in order to ensure that the temperature of the gas in the enclosure {6} reaches a predetermined value.

2. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein said means are arranged to control the temperature of the gas at the predetermined location {80}, in order to ensure that the temperature at this location reaches a predetermined value.

3. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein said means are arranged to cool the gas.

4. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein said means are arranged to heat the gas.

5. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein said means are arranged to control the relative humidity of the gas.

6. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein said means include at least one particle filter {30, 32}.

7. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein said means include at least one fan {10, 14} placed upstream or downstream of the enclosure {6, 8, 10} ~~for example~~.

8. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein the enclosure {6} includes devices {39} for shaping of the tablets.

9. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein the enclosure {8} includes a motor.

10. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ the enclosure (10) includes an electronic device.

11. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ the enclosures (6, 8, 10) are at least two in number, and the machine includes means for injecting a gas into each enclosure and to distribute it.

12. (Currently Amended) An installation according to ~~the preceding claim characterised in that claim 11, wherein~~ it includes gas conduits (16) arranged to feed gas to the enclosures (6, 8, 10) using a parallel arrangement.

13. (Currently Amended) An installation according to any of claims 11 or 12, ~~characterised in that wherein~~ the means are partially common to the enclosures (6, 8, 10).

14. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ said means include at least one gas conduit (16) connected so that it can be removed from the enclosure (6, 8, 10).

15. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ it includes at least one stopper (36a-c, 70) to interrupt the flow of gas between the enclosure and the remainder of the installation.

16. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ said means are arranged to control a flow of gas associated with the enclosure by allowing the choice of one flow from various non-zero flow values.

17. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ said means include a diffusion box (40, 50, 62) placed in the enclosure (6, 8, 10), having at least two openings (42) for entry of the gas into the enclosure.

18. (Currently Amended) An installation according to ~~the preceding claim characterised in that claim 17, wherein~~ the openings (42) are located on different faces of the diffusion box (40, 50, 62).

19. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that claim 1, wherein~~ the tablets include a substance for therapeutic or cosmetic use.

20. (Currently Amended) An installation according to ~~any of the preceding claims, characterised in that~~ claim 1, wherein the tablets include Ibuprofen.

21. (Currently Amended) A process for the production of tablets, ~~characterised in that~~ wherein gas is injected into an enclosure ~~{6, 8, 10}~~ that forms part of a machine ~~{2}~~ for the production of tablets, and is distributed throughout the enclosure, and in that the temperature of the gas is controlled at a predetermined location ~~{80}~~ upstream of the enclosure in order to ensure that the temperature of the gas in the enclosure reaches a predetermined value.

22. (Currently Amended) A process according to ~~the preceding claim, characterised in that~~ claim 21, wherein the temperature of the gas is controlled at the predetermined location ~~{80}~~ in order to ensure that the temperature at this location reaches a predetermined value.

23. (New) A method for the production of tablets, wherein a gas is fed into an enclosure that forms part of a machine for the production of tablets, and distributed throughout the enclosure.

24. (New) A method according to claim 23, wherein the temperature of the gas is controlled.

25. (New) A method according to claim 23, wherein the temperature of the gas is controlled at a predetermined location upstream of the enclosure, in order to ensure that the temperature of the gas in the enclosure reaches a predetermined value.

26. (New) A method according to any of claims 23 to 25, wherein the temperature of the gas is controlled at a predetermined location upstream of the enclosure so that the temperature reaches a predetermined value.